



Form PTO-1449 (modified)

List of Patents and Publications for Applicant

INFORMATION DISCLOSURE STATEMENT

(Use several sheets if necessary)

Atty. Docket No.

2000.109700/DE0351

Serial No.

10/747,722

Applicant

Axel Preusse, Markus Nopper and Holger Schuhrer

Filing Date:

December 29, 2003

Group:

2811

U.S. Patent Documents

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Foreign Patent Documents

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Other Art

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U.S. Patent Documents

Exam. Init.	Ref. Des.	Document Number	Date	Name	Class	Sub Class	Filing Date of App.
501	A1	5,091,047	2/25/92	Cleaves <i>et al.</i>	156	643	
	A2	5,340,435	8/23/94	Ito <i>et al.</i>	156	632	
	A3	5,966,628	10/12/99	Wei <i>et al.</i>	438	584	
501	A4	6,150,696	11/21/00	Iwamatsu <i>et al.</i>	257	347	
	A5						

Foreign Patent Documents

Exam. Init.	Ref. Des.	Document Number	Date	Country	Class	Sub Class	Translation Yes/No
	B1						
	B2						
	B3						

Other Art (Including Author, Title, Date Pertinent Pages, Etc.)

Exam. Init.	Ref. Des.	Citation
501	C1	Wolf <i>et al.</i> , SILICON PROCESSING FOR THE VLSI ERA, Vol. 1: Process Technology, pp. 400-403 and 532-533, 1986
	C2	
	C3	

EXAMINER:

501

DATE CONSIDERED:

10-25-04

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